

## current efficiency

**Also contains definition of:** metal distribution

If several reactions take place simultaneously at the electrode a partial electrode current density (c.d.)  $j_k$  can be assigned to each reaction. It is given by the stoichiometry of the reaction and by the amount of substance of **B** reacting (per unit time and per unit electrode area) in the reaction considered. The current efficiency of reaction  $k$ ,  $\varepsilon_k$  is defined as the ratio of  $j_k$  to the total c.d.:

$$\varepsilon_k = \frac{j_k}{\sum_m j_m}$$

Note that  $\varepsilon_k$  may be larger than one if cathodic and anodic reactions take place simultaneously at the same electrode. However,  $\varepsilon_k$  still gives correctly the product yield, which is the quantity of industrial interest. The product yield is the amount of substance of **B** produced per unit charge and is equal to  $\frac{\varepsilon_k \nu_{B,k}}{n_k F}$  (in the absence of a chemical reaction which is consecutive to the electrode reaction and which consumes or produces species **B**).  $n_k$  is the charge number of electrode reaction  $k$ . Note that in the case of simultaneous electrode reactions the distribution of the partial c.d.  $j_k$  may be different from that of the total c.d., i.e. the function  $\frac{(j_k)_x}{j} = f_k(x)$  may be different from  $\frac{j_x}{j} = f(x)$ . In electroplating the term 'metal distribution' is sometimes used to designate the distribution  $f_k(x)$  of the partial c.d. for metal deposition.

**Source:**

PAC, 1981, 53, 1827 (*Nomenclature for transport phenomena in electrolytic systems*) on page 1836